Engineering Faculty Document No. 53-06 May 10, 2007

- **TO:** The Faculty of the College of Engineering
- **FROM:** The Faculty of the School of Electrical and Computer Engineering
- **RE:** ECE 658 Change in Course Description and Terms Offered

The faculty of the School of Electrical and Computer Engineering has approved the following changes in ECE 658. This action is now submitted to the Engineering Faculty with a recommendation for approval.

From: **ECE 658** Semiconductor Material and Device Characterization Sem. 2. Class 3, cr. 3. (Offered in alternate years.) Prerequisite: ECE 606. Authorized equivalent courses or consent of instructor may be used in satisfying course pre- and co-requisites. A comprehensive survey of modern characterization techniques routinely used to determine solid-state material and device parameters. Concepts and theory underlying the techniques are examined, and sample experimental results are presented. The coverage includes electrical, optical, chemical, and physical characterization methods. ECE 658 Semiconductor Material and Device Characterization To: Sem. 2, even years. Class 3, cr. 3. Prerequisite: ECE 606. Authorized equivalent courses or consent of instructor may be used in satisfying course pre- and co-requisites. An examination of modern characterization techniques routinely employed to determine semiconductor material and device parameters. Concepts and theory

Reason: The course description has been changed to reflect the increased emphasis on techniques employing electrical measurements. The terms offered has been changed to meet the needs of the school.

underlying the techniques are reviewed, and sample experimental results are presented. Emphasis is on techniques employing electrical measurements.

M. J. T. Smith, Head School of Electrical & Computer Engineering

ECE 658 Semiconductor Material and Device Characterization

Required Text: D. K. Schroder, *Semiconductor Material and Device Characterization*, 3rd edition, John Wiley & Sons, © 2006; ISBN-13: 978-0-471-73906-7 and ISBN-10: 0-471-73906-5.

Weeks Principal Topics

- 1 Resistivity and type measurements
- 2 Semiconductor doping measurements and profiling
- 1 2/3 Barrier height and contact resistance measurements
- 1 Series resistance and related measurements
- 1 1/3 Deep-level parameter measurements
- 1 1/3 Measurement of oxide and interface parameters in MOS devices
- 1 1/3 Measurement of MOSFET channel parameters
- 2 1/3 Carrier lifetime measurements
 - 1 Carrier mobility measurements
 - 2 Demonstrations and midterm exam